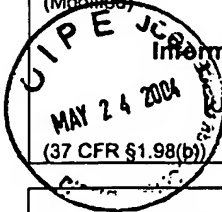


Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. <b>10559-894001</b>	Application No. <b>10/763,467</b>
<b>Information Disclosure Statement by Applicant</b> (Use several sheets if necessary)		Applicant <b>Hai Deng et al.</b>	
		Filing Date <b>January 22, 2004</b>	Group Art Unit



U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
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	AF						
	AG						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AH							
	AI							
	AJ							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Desig. ID	Document
<i>ML</i>	AK	Myoung Soo Kim, et al.; Effect on Salt on the Dissolution of Novolak in Base; March 1997; SPIE, Vol. 3049; pps. 528-534
	AL	M. Switkes, et al.; Resolution Enhancement of 157 nm Lithography by Liquid Immersion; 2002; SPIE, Vol. 4691; pps. 459-465
<i>J</i>	AM	Soichi Owa, et al.; Immersion lithography; its potential performance and issues; 2003; SPIE, Vol. 5040; pps. 724-733
<i>J</i>	AN	M. Switkes, et al.; Immersion Liquids for Lithography in the Deep Ultraviolet; 2003; SPIE, Vol. 5040; pps. 690-699

Examiner Signature <i>Charles Li</i>	Date Considered <i>12/26/06</i>
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	